

### **REMARKS**

Claims 2-11 are pending in the present application. Claims 1, 2, 5-8 and 10 were rejected under 35 U.S.C. § 102(a) over Ishida, et al. ("Sub-10-nm-Scale Lithography Using *p*-chloromethyl-methoxy-calix[4]arene Resist", Jpn. J. Appl. Phys., Vol. 42 (2003), pg. 3913-3916) ("Ishida"). Claim 1 was rejected under 35 U.S.C. §102(b) over Nagasaki, et al. ("Novel Conformational Isomerism of Water-Soluble Calix[4]arenes", Tetrahedron, 1992, Vol. 48 (5), pg. 797-804) ("Nagasaki"). Claim 1 has been canceled hereby without prejudice. Reconsideration of the application in light of the above amendment and below remarks is respectfully requested.

Claim 1 has been rejected under § 102(b) as being anticipated by Nagasaki. This rejection is moot in view of the cancellation of claim 1.

Claims 1, 2, 5-8 and 10 have been rejected under § 102(a) as being anticipated by Ishida. Applicants respectfully traverse this rejection.

Ishida is not prior art to the present application. Ishida has an effective date of June 2003, the publication date. *See* MPEP § 2128.02 (stating that the effective date of a printed publication is its publication date, not its date of receipt by the publisher). Applicants reduced the claimed invention to practice before June 2003. As evidence of this fact, submitted herewith is a verified translation of the Japanese priority application from which the present application claimed benefit. The Japanese priority application was filed on September 9, 2002. The filing of the Japanese priority application constitutes constructive reduction to practice. Thereafter, a PCT based on the Japanese priority application was filed on September 4, 2003. The present U.S. national phase application was properly filed within 30 months of the PCT. The Japanese priority application and subsequent filings therefore show that the application covering the claimed invention was reduced to practice before Ishida.

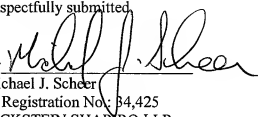
In view of the above-mentioned evidence of Applicants' reduction to practice of the claimed invention, the rejection based upon 35 U.S.C. § 102(a) should be withdrawn.

In view of the above amendment, Applicants believe the pending application is in condition for allowance.

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Respectfully submitted,

By

  
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